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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/774,489	02/10/2004	Hiroshi Sotozaki	2004_0208	8916
513 7:	590 09/26/2005		EXAMINER	
WENDEROTH, LIND & PONACK, L.L.P.			MACARTHUR, SYLVIA	
2033 K STREET N. W.				
SUITE 800		·	ART UNIT	PAPER NUMBER
WASHINGTO	ON, DC 20006-1021		1763	

DATE MAILED: 09/26/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

			W			
	Application No.	Applicant(s)				
	10/774,489	SOTOZAKI ET AL.				
Office Action Summary	Examiner	Art Unit				
	Sylvia R. MacArthur	1763				
The MAILING DATE of this communication ap Period for Reply	pears on the cover sheet w	ith the correspondence address				
A SHORTENED STATUTORY PERIOD FOR REPL WHICHEVER IS LONGER, FROM THE MAILING D - Extensions of time may be available under the provisions of 37 CFR 1. after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory period - Failure to reply within the set or extended period for reply will, by statut Any reply received by the Office later than three months after the mailine earned patent term adjustment. See 37 CFR 1.704(b).	DATE OF THIS COMMUNI 136(a). In no event, however, may a will apply and will expire SIX (6) MOI e, cause the application to become A	CATION. reply be timely filed NTHS from the mailing date of this communication BANDONED (35 U.S.C. § 133).				
Status						
1) Responsive to communication(s) filed on 22 J	<u>lune 2005</u> .					
2a)⊠ This action is FINAL . 2b)☐ This	☐ This action is FINAL . 2b)☐ This action is non-final.					
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is						
closed in accordance with the practice under	Ex parte Quayle, 1935 C.). 11, 453 O.G. 213.				
Disposition of Claims						
4) Claim(s) 1,10-15 and 22-33 is/are pending in	the application.					
4a) Of the above claim(s) is/are withdrawn from consideration.						
5) Claim(s) is/are allowed.						
6)⊠ Claim(s) <u>1,10-15 and 22-33</u> is/are rejected.						
7) Claim(s) is/are objected to.	·					
8) Claim(s) are subject to restriction and/o	or election requirement.					
Application Papers						
9) The specification is objected to by the Examine	er.					
10)⊠ The drawing(s) filed on <u>10 February 2004</u> is/are: a)⊠ accepted or b)□ objected to by the Examiner.						
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).						
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).						
11) The oath or declaration is objected to by the E	xaminer. Note the attache	d Office Action or form PTO-152.				
Priority under 35 U.S.C. § 119						
12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of:						
1. Certified copies of the priority documents have been received.						
2. Certified copies of the priority documents have been received in Application No						
3. Copies of the certified copies of the priority documents have been received in this National Stage						
application from the International Bureau (PCT Rule 17.2(a)).						
* See the attached detailed Office action for a list of the certified copies not received.						
•						
Attachment(s)						
Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-948)		Summary (PTO-413) s)/Mail Date				
Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date		nformal Patent Application (PTO-152)				
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DETAILED ACTION

Claim Rejections - 35 USC § 102

1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- (e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.
- 2. Claims 1, 10-15, and 22-33 are rejected under 35 U.S.C. 102(b) as being anticipated by Togawa (EP 0761387)

Togawa teaches a polishing apparatus and a method of polishing and then cleaning susbstrates comprising at least two polishing units/section (1a,1b) and cleaning unit (7a,7b,8a,8b). The cleaning units 7a, 7b (first cleaning units) and cleaning units/common second cleaning unit (8a,8b). Cleaning units 8a,8b also serves as a drying unit, according page 4 lines 42-49. According to the cleaning units 7a,7b perform the same cleaning function see page 4, lines 47-49. The first cleaning unit cleans one substrate at a time as described in page 5 lines 41-52. Transfer robots 4a, 4b are used as conveyor to the substrate throughout the polishing apparatus. Claims 11 and 12 of Togawa cites that a parallel processing is performed is such that a workpiece is polished by a polishing unit and cleaning unit.

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Regarding claims 14 and 31: Togawa fails to specify that the cleaning unit supplies an etching liquid. Nevertheless, Togawa does cite in page 2 line 29 that the wafer is cleaned by water.

3. Claims 1, 10-15, and 22-33 rejected under 35 U.S.C. 102(e) as being anticipated by Katsuoka et al (US 6,918,814).

Katsuoka et al teaches a pair of polishing units 10a,10b, a pair of primary cleaning units 18a,b, and secondary cleaning units of 14a,b. Col7 line 22 Katsuoka et al teaches that the polishing apparatus works in a parallel fashion, see col. 7 lines 34-43.

Regarding claims 14 and 31: Katsuoka et al fails to specify that the cleaning unit supplies an etching liquid. Nevertheless, Katsuoka et al does cite in col. 7 lines 45-58 that the wafer is cleaned by water.

Response to Arguments

2. Applicant's arguments with respect to claims 1 and 10-15 have been considered but are most in view of the new ground(s) of rejection.

Togowa et al (EP 0761387) teaches parallel processing of workpieces with a polishing and cleaning modules.

Katsuoka et al (US 6,918,814) teaches a polishing apparatus and method utilizing polishing and cleaning modules.

Conclusion

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3. Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

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A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Sylvia R. MacArthur whose telephone number is 571-272-1438. The examiner can normally be reached on M-F during the core hours of 9 a.m. and 3 p.m.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Parviz Hassanzadeh can be reached on 571-272-1435. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Sylvia R MacArtl Patent Examiner Art Unit 1763

September 19, 2005

PARVIZ HASSANZADEH